

12-10-01

A

FROMMER LAWRENCE & HAUG LLP
745 FIFTH AVENUE
NEW YORK, NEW YORK 10151
TEL. (212) 588-0800

Date: December 4, 2001

Re: 450110-03698

ASSISTANT COMMISSIONER FOR PATENTS
Box Patent Application (35 U.S.C. 111)
Washington, D.C. 20231

Sir:

With reference to the filing in the United States Patent and Trademark Office
of a Continuation application of a PCT application, pursuant to 35 U.S.C.
111(a) in the name(s) of:

Jonathan James STONE

entitled:

WATERMARKED MATERIAL PROCESSING

The following are enclosed:

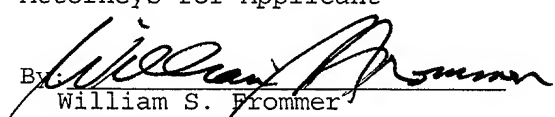
- ☒ Specification (17 pages)
- ☒ 4 Sheet(s) of Drawings
- ☒ 37 Claim(s) (including 6 independent claim(s))
- ☐ This application contains a multiple dependent claim
- ☒ Oath or Declaration and Power of Attorney ☐ signed ☒ unsigned
- ☒ Preliminary Amendment
- ☒ Our check for \$ 740.00, calculated as follows:

Basic Fee, \$740.00 (\$370.00)	\$ 740.00
Number of Claims in excess of 20 at \$18.00 (\$9.00) each:	306.00
Number of Independent Claims in excess of 3 at \$84.00 (\$42.00) each:	252.00
Multiple Dependent Claim Fee at \$280.00 (\$140.00)	-0-
Total Filing Fee	\$ 1,298.00
Assignment Recording Fee \$40.00	-0-
- ☒ Pursuant to MPEP § 1895, enclosed is a copy of the PCT Request which is submitted as evidence that the instant continuation is copending with the PCT application and has at least one inventor in common therewith.
- ☒ Certified copy of each of the following application(s) to substantiate the claim(s) for priority made in the Declaration to follow:

<u>Application No.</u>	<u>Filed</u>	<u>In</u>
0008439.2	5 April 2000	U.K.
0019977.8	14 August 2000	U.K.

Please charge any additional fees required for the filing of this application or credit any overpayment to Deposit Account No. 50-0320.

Respectfully submitted,
FROMMER LAWRENCE & HAUG LLP
Attorneys for Applicant

By: 
William S. Frommer
Reg. No. 25,506

J1046 U.S. PTO
10/006743
12/04/01

jc698 U.S. PTO
12/04/01

"Express Mail" mailing label number: EV001579515US

Date of Deposit: December 4, 2001

I hereby certify that this paper or fee, and a patent application and accompanying papers are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and is addressed to the U.S. Patent and Trademark Office, Box Patent Application (35 U.S.C. 111), P.O. Box 2327, Arlington, VA 22202.

Edward Nay

(Typed or printed name of person mailing paper or fee)

Edward Nay

(Signature of person mailing paper or fee)

FROMMER LAWRENCE & HAUG LLP

745 FIFTH AVENUE NEW YORK, NEW YORK 10151

December 4, 2001

U.S. Patent and Trademark Office
Box Patent Application (35 U.S.C. 111)
P.O. Box 2327
Arlington, VA 22202

Re: **Continuation of PCT Application - 35 U.S.C. 111(a)**
Applicant: Jonathan James STONE
Our Ref.: 450110-03698

Dear Sir:

Enclosed are papers constituting the above patent application which is being filed under 37 C.F.R. 1.53 as a **Continuation of a PCT application pursuant to 35 U.S.C. 111(a)** without a signed Declaration. Please accord a filing date and a serial number to such application and inform the undersigned thereof so that a signed Declaration and the surcharge required by 37 C.F.R. 1.16(e) may be duly filed.

Please address all correspondence to:

William S. Frommer, Esq.
FROMMER LAWRENCE & HAUG LLP
745 Fifth Avenue
New York, New York 10151
Tel. (212) 588-0800

Respectfully,



William S. Frommer
Reg. No. 25,506
Attorney for Applicant
Enclosures

WILLIAM S. FROMMER
WILLIAM F. LAWRENCE
EDGAR H. HAUG
MATTHEW K. RYAN
BARRY S. WHITE
THOMAS J. KOWALSKI
JOHN R. LANE
DENNIS M. SMID*
DANIEL C. BROWN
BARBARA Z. MORRISSEY
STEVEN M. AMUNDSON
MARILYN MATTHEW BROGAN
JAMES K. STRONSKI
CHARLES J. RAUBICHECK
GRACE L. PAN*
GORDON KESSLER
MARK W. RUSSELL*
JEFFREY A. HOVDEN
RONALD R. SANTUCCI

A. THOMAS S. SAFFORD
JEROME ROSENSTOCK
RAYMOND R. WITTEKIND, PH.D.
SUSAN K. LEHNHARDT, PH.D.
RICHARD E. PARKE
Of Counsel

BRUNO POLITO
JOE H. SHALLENBURGER
CHRISTIAN M. SMOLIZZA
GLENN F. SAVIT
ROBERT E. COLLETTI
DEXTER T. CHANG
LINDSEY A. MOHLE
DEENA P. LEVY
DARREN M. SIMON
JOHN G. TAYLOR
DAVID A. ZWALLY
SAMUEL H. MECERDITCHIAN
KEVIN MURPHY
TERRI-LEE YOUNG
PEARL TENG LING SIEW
RICHARD A. MASTROCOLA
DAMON A. TREITLER
TEDD W. VAN BUSKIRK
*Admitted to a Bar
other than New York